

THE SPIN COATER FAMILY



Novel Spin Coater are ideal tools to prepare thin and ultrathin films especially for spectroscopic applications (optical, IR, X-ray, dielectric etc.). By applying rotational speeds up to 19.000 rpm thin and ultrathin layers of extraordinary homogeneity can be achieved. All Spin Coaters are high-quality / low cost products with 2 years warrantee.



The well known Spin coaters of the SCI-Series feature

- Rotational speed up to 19.000 rpm
- Film thickness range 10 nm to 10 μ m
- Easy-to-use and maintenance-free design

Due to a novel design of the rotational platform the substrate is hold tightly on which the sample is to be deposited.

The NEW Spin coaters of the SCV-Series feature

- Rotational speed up to 12.000 rpm
- Active vacuum suction of the sample
- Film thickness range 10 nm to 10 μ m
- Easy-to-use and maintenance-free design
- Rotational platforms up to 90 mm diameter



The high end Spin Coaters of the SCE-Series feature

all the properties of the SCV-Series, but

- rotational platforms up to 110 mm diameter
- ramp function for the rotational speed

To make it complete we offer the small vacuum pump MVP

- vacuum of -33,3 kPa
- flow of 7l/min
- noise of max. 40dB(A)

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